

PRESS RELEASE

More than 150 Participants at the HEPTech AIME on Cryogenics in Grenoble

The first “HEPTech Academia Meets Industry on Cryogenics” took place on June 4th -5th 2015 in Grenoble, France and attracted 154 participants, representatives of research and industry, from 15 countries (12 European countries, Japan, USA and India).

Cryogenics has widely contributed to the recent major achievements of high energy physics (HEP). And conversely, HEP has pushed cryogenic engineering developments to a high level of technical excellence.



HEPTech organized this event in partnership with the European Cryogenics Society (ECS) and the European Enterprise Network (EEN), together with CNRS, CEA, Grenoble University, Lanef, ILL, CERN, the University of Twente, and the Rutherford Appleton Laboratory. The forum was also supported and hosted by the CCI (“Chambre de Commerce et d’Industrie de Grenoble”).

The AIME aimed at building and strengthening links in the European Cryogenics Community. A comprehensive program explored the subject of Cryogenics providing an overview of the future cryogenic systems for high energy physics research projects at particle accelerators, neutron facilities as well as in related applications, including Cryogenics for Astrophysics/HEP in Space and industrial spin-offs: MRI, NMR and energy-related applications.



The event hosted the first meeting of the new Cryogenics Society of Europe (CSE), bringing together the world leading experts in the field. This fact, along with the support of the EEN, provided a unique opportunity for scheduled face to face meetings of industry representatives and leading experts in Cryogenics and project leaders with exciting and challenging needs in terms of development and manufacturing of future cryogenics systems.

All parties acknowledged the success of the event, thus setting up the basis for a continuous collaboration between HEPTech, the EEN and the Cryogenics Society of Europe, and sharing the idea to replicate forums of the same nature in the future.

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